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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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10/822,189

04/09/2004

Gracme Huntley

M00A223

2314

7590

06/22/2007

The BOC Group, Inc.
Legal Services-Intellectual Property
575 Mountain Ave.
Murray Hill, NJ 07974

EXAMINER

WIEHE, NATHANIEL EDWARD

ART UNIT

PAPER NUMBER

3745

MAIL DATE

DELIVERY MODE

06/22/2007

PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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Office Action Summary	Application No.	Applicant(s)	
	10/822,189	HUNTLEY ET AL.	
	Examiner	Art Unit	
	Nathan Wiehe	3745	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☐ Responsive to communication(s) filed on ____.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-19 is/are pending in the application.
- 4a) Of the above claim(s) ____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) ____ is/are allowed.
- 6) ☒ Claim(s) 1-19 is/are rejected.
- 7) ☐ Claim(s) ____ is/are objected to.
- 8) ☐ Claim(s) ____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 09 April 2004 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. ____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|---|--|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413),
Paper No(s)/Mail Date. ____. |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)
Paper No(s)/Mail Date <u>04092004</u> . | 6) <input type="checkbox"/> Other: ____. |

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1-5,9-16 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Reimer et al. (7,077,159), hereinafter "Reimer" in view of Stones (6,375,413). Reimer discloses a load-lock (110) and pump (165c) wherein the pump (165c) that is directly connected to and abutting the load-lock on its bottom wall (110) (Reimer column 6, lines 48-52). Reimer's load-lock further includes loading and unloading ports. However Reimer is silent as to the construction of the vacuum pump (110). Stones discloses a dry vacuum pump (1) including a shaft (4) rotor (6) with first (16) and second (17) concentric cylinders extend outwardly from the rotor and an upper housing portion (3) having flanges (14,13) with helical structures mounted thereon and forming a Holweck molecular drag compression stage. The flanges are provided on the inner facing surface of the flange-like cylinder (14) and both the inner and outer facing surface of the cylinder (13) (See Fig. 1). The pump also includes a regenerative compression stage formed by a plurality of concentric circular channels (c) in the body portion (3) and respective raised rings (B) on the lower surface of the rotor (6). Stones' vacuum pump provides for lower power consumption, an ability to assemble and disassemble the rotor from the pump body and an overall compact design (Stone column

2, lines 47-48). Therefore, It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the load-lock arrangement of Reimer by utilizing a dry vacuum pump as taught by Stones for the purpose of providing a pump with lower power consumption, an ability to assemble and dis-assemble the rotor from the pump body and an overall compact design. Following the teaching of Reimer, i.e. the direct connection of the pump to the load-lock, the upper body portion of Stones, shown with an unnumbered bolting flange, is being construed to be the claimed mating system.

Claims 6-8,17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Reimer et al. (7,077,159), hereinafter "Reimer" in view of Stones (6,375,413) as applied to claims 5 and 16 above, and further in view of Toshima et al. (6,545,508), hereinafter "Toshima". The modified invention of Reimer does not disclose the use of a multiple load-lock chambers. Toshima discloses a load-lock with a first (8) and second (9) chamber that maybe pumped down separately and individually by a single pump (Toshima column 2, lines 57-59). It is noted that the use of a single pump would inherently require a valve system isolating the first and second chambers form the pump. The use of two load-lock chambers significantly increases throughput of wafers through the processing system (Toshima column 1, lines 38-44). Further, Toshima discloses the use of slit valves (21) that operate to effectively seal the various chambers of the processing system (Toshima column 3, lines 28-29). Therefore, It would have been obvious to one of ordinary skill in the art at the time the invention was made to further modify the invention of Reimer by including a load-lock having two chambers

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and slit valves for the purpose of increasing throughput of the processing system as well as effectively sealing the respective chambers of the system.

Conclusion


Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nathan Wiehe whose telephone number is (571)272-8648. The examiner can normally be reached on Mon.-Thur. and alternate Fri., 7am-4:30pm EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Edward Look can be reached on (571)272-4820. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.


EDWARD K. LOOK
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 3700

6/20/07


Nathan Wiehe
Examiner
Art Unit 3745